Search Notes				

Application/Control No.	Applicant(s)/Patent under Reexamination
10/064,971	LIN ET AL.
Examiner	Art Unit
Jacob P. Rohwer	2625

SEARCHED					
Class	Subclass	Date	Examiner		
399	166	4/19/2006	JPR		
434	353	4/20/2006	JPR		
			-		
		1 100 1 100 100 100 100 100 100 100 100			

INTERFERENCE SEARCHED				
Class	Subclass	Date	Examiner	

SEARCH N (INCLUDING SEARC)
	DATE	EXMR
East Text Search Class 358/1.14	4/19/2006	JPR
East Text Search See Attached	4/20/2006	JPR
101/484 and 400/476 (With Terms)	7/25/2006	JPR
East (Updated) See Attached	7/27/2006	JPR